Accepted Manuscript

Novel in-situ lamella fabrication technique for in-situ TEM

Megan Canavan, Dermot Daly, Andreas Rummel, Eoin K. McCarthy, Cathal McAuley, Valeria Nicolosi

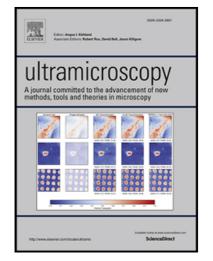
 PII:
 S0304-3991(17)30357-1

 DOI:
 10.1016/j.ultramic.2018.03.024

 Reference:
 ULTRAM 12561

To appear in: Ultramicroscopy

Received date:	3 August 2017
Revised date:	22 March 2018
Accepted date:	28 March 2018



Please cite this article as: Megan Canavan, Dermot Daly, Andreas Rummel, Eoin K. McCarthy, Cathal McAuley, Valeria Nicolosi, Novel in-situ lamella fabrication technique for in-situ TEM, *Ultra-microscopy* (2018), doi: 10.1016/j.ultramic.2018.03.024

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.

Highlights

- A novel in-situ lamella fabrication technique for in-situ TEM annealing is proposed
- Use of rotating microgrippers and unique adhesive for lamella thinning and mounting
- Removes the risk of Pt re-deposition and ion beam damage to the MEMS device

ACERTER

Download English Version:

https://daneshyari.com/en/article/8037659

Download Persian Version:

https://daneshyari.com/article/8037659

Daneshyari.com